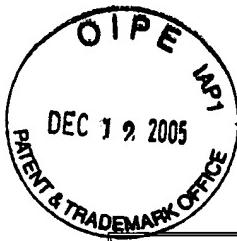


IPW



PATENT
03345-P0047A WWW/CHS

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants	Markus Schwambera, <i>et al.</i>
Serial No. 10/754,817	Filing Date: January 9, 2004
Title of Application:	Process Chamber with a Base with Sectionally Different Rotational Drive and Layer Deposition Method in Such a Process Chamber
Confirmation No. 1549	Art Unit: 1763
Examiner	Sylvia R. Mac.Arthur

Mail Stop Amendment
Commissioner for Patents
Post Office Box 1450
Alexandria, VA 22313-1450

Response to Official Action

In response to the Official Action of September 8, 2005, Applicants herewith present its amendment and remarks. Please amend the claims as detailed below.

Applicant believes that no fee is due in connection with the filing of this Amendment. However, if any fee is due please charge Deposit Account No. 19-4516.

Mailing Certificate: I hereby certify that this correspondence is today being deposited with the U.S. Postal Service as *First Class Mail* in an envelope addressed to: Commissioner for Patents and Trademarks; Post Office Box 1450; Alexandria, VA 22313-1450.

December 8, 2005

Patricia A. Sci